

**LaboratoryName: Idaho National  
Laboratory  
B&R Code: KC 0202010**

**FWP and possible subtask under FWP:**

Structural and Electrostatic Effects in Interface and Nanostructure Growth

**FWP Number: 3E106(100390)**

**Program Scope:** The goal of this work is to explore some of the ways that non-idealities in solids, such as interfaces, surfaces and defects, affect their materials properties of relevance to the DOE missions. Specifically, it explores (1) the dynamics of compound formation at metal/semiconductor interfaces, including the formation of metastable compounds; (2) the role of surface bonding in determining nanoparticle binding energies, and hence their melting, sublimation and sintering behaviors; and (3) the effect of substitutional defects on the properties of layered superconductors.

**Major Program Achievements (over duration of support):**

The most tangible achievements to date are the following publications:

- 1) H. H. Farrell, C. D. Van Siclen, D. M. Ginosar, L. M. Petkovic, and R. D. Parra, "Surface Bonding Effects in Nanoparticles: Stoichiometric Compound Semiconductors" submitted to *J. Vac. Sci. Technol.B*.
- 2) H. H. Farrell and C. D. Van Siclen, "Binding Energy, Vapor Pressure, and Melting Point of Semiconductor Nanoparticles", *J. Vac. Sci. Technol.B*, **25**, 1441 (2007).
- 3) H. H. Farrell and R. A. LaViolette, "Diatomic Substitutionals in Superconducting  $Nb_{(1-x)}B_2$ ", *Physica C-Superconductivity and Its Applications*, **449** 1 (2006).
- 4) H. H. Farrell, J. L. Hilton, B. D. Schultz BD, C. J. Palmström, "Nonequilibrium Phases in Epitaxial Mn/GaAs Interfacial Reactions" *J. Vac. Sci. Technol. B* **24**, 2018 (2006).
- 5) H. H. Farrell, A. B. Denison, "Semi-empirical inelastic mean free paths for positrons", *Surface and Interface Analysis*, **37**, 529 (2005).
- 6) H. H. Farrell and R. A. LaViolette, "Anion Variations at Semiconductor Interfaces: ZnSe(100)/GaAs(100)", *J. Vac. Sci. Technol. B*, **23**, 406 (2005).

Publications in preparation include:

- 7) Sergey N. Rashkeev, Daniel M. Ginosar, Lucia M. Petkovic, and Helen H. Farrell, "Catalytic Activity of Supported Metal Particles for Sulfuric Acid Decomposition Reaction", in preparation.
- 8) H. H. Farrell and R. D. Parra, "Binding Energy of Oxide Particles", to be submitted to *J. Phys. Chem. B*.
- 9) R. D. Parra and H. H. Farrell, "Copper Oxide Clusters", to be submitted to the *J. Chem. Phys.*
- 10) H. H. Farrell, "Binding Energies of Compound Semiconductor Nanoparticles", to be submitted to *J. Vac. Sci. Technol.B*.
- 11) H. H. Farrell and Randall A. LaViolette, "The McMillan Equation as Applied to Metal Diborides", to be resubmitted to *Phys. Rev. Lett.*

Papers 2, 4 and 6 have also been given as talks at the '05, '06, and '07 annual PCSI meetings, respectively. An extension of paper 6 was also given at the 2005 MRS meeting and paper 1 was given at the 2007 AVS meeting. An invited talk entitled "Computational Modeling of Nanostructures" was given at the NSF sponsored workshop "United States-Ireland Partnership Nanotechnology Workshop", Belfast, Northern Ireland, October 23rd and 24th, 2006.

**Program impact:**

Work progresses on understanding the relationship between the forces that govern the formation of defects, surface and interfaces, and their effects on the relevant materials properties.

**Interactions:** Idaho National Laboratory; C. D. Van Siclen, D. M. Ginosar, L. M. Petkovic, S. Rashkeev. Sandia National Laboratory; R. A. LaViolette (formerly INL).

University of Minnesota at Minneapolis; C. J. Palmstrom. DePaul University; R. D. Parra. Pennsylvania State University; Darrell Schlom,

**Recognitions, Honors and Awards (at least partly attributable to support under this FWP or subtask):**

Laboratory Director's Award for Individual Lifetime Achievement in Science and Technology. Program Committee: Physics and Chemistry of Semiconductor Surfaces Annual Meetings.

**Personnel Commitments for FY2007 to Nearest +/- 10%:**

Helen H. Farrell, 50 %.

**Authorized Budget (BA) for FY05, FY06, FY07:**

**FY02 BA \$200K**

**FY03 BA \$200K**

**FY04 BA \$200K**